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## (54) PHOTOSENSITIVE COMPOSITION

## (57)Abstract:

PROBLEM TO BE SOLVED: To provide a photosensitive composition having proper adhesiveness with respect to a glass surface and in aging stability and is suitable for use in the formation of the black matrix of a color cathode-ray tube.

SOLUTION: The photosensitive composition comprises 70-99.5 mass% water- soluble vinyl copolymer (A) comprising the units of a water-soluble monomer (a), having a group selected from among a carboxylic acid group, an acid anhydride group, a sulfonic acid group, a phosphoric acid group and their salts, and Nvinylpyrrolidone units and 0.5-30 mass% water-soluble azido compound (B).

## LEGAL STATUS

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